Multi-beam multi-wavelength semiconductor lasers

Nantang Yu,1,a) Mikhail A. Kats,1 Christian Pflügl,1 Markus Geiser,1 Qi Jie Wang,1,b) Mikhail A. Belkin,1,6 Federico Capasso,1,d) Milan Fischer,2 Andreas Wittmann,2 Jérôme Faist,3 Tadataka Edamura,4 Shinichi Furuta,3 Masahironi Yamanishi,3 and Hirofumi Kan1

1School of Engineering and Applied Sciences, Harvard University, Cambridge, Massachusetts 02138, USA
2Institute of Quantum Electronics, ETH Zürich, CH-8093 Zürich, Switzerland
3Central Research Laboratory, Hamamatsu Photonics K.K., Hamamatsu 434-8601, Japan

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Multibeam emission and spatial wavelength demultiplexing in semiconductor lasers by patterning their facets with plasmonic structures is reported. Specifically, a single-wavelength laser was made to emit beams in two directions by defining on its facet two metallic gratings with different periods. The output of a dual-color laser was spatially separated according to wavelength by using a single metallic grating. The designs can be integrated with a broad range of active or passive optical components for applications such as interferometry and demultiplexing. © 2009 American Institute of Physics. [doi:10.1063/1.3253713]

Beam engineering of semiconductor light sources by patterning plasmonic structures directly on their emission facet has been actively pursued in recent years.1–10 This approach allows for the creation of light sources with enhanced performance and/or new functionalities. These sources can then be used for a variety of applications without resorting to external optical components for beam shaping. For example, plasmonic structures have been used to enhance directionality and increase the emitted optical power of light-emitting diodes.4,5 The problem of polarization instability in vertical-cavity surface-emitting lasers (VCSELs) has been addressed by patterning anisotropic plasmonic patterns on the device facet.6,7 Plasmonic collimators have been shown to reduce beam divergence of edge-emitting quantum cascade lasers (QCLs) by orders of magnitude while preserving their power output.8,9 Plasmonics have been demonstrated as a promising and technologically simple approach for achieving polarization control in semiconductor lasers.10

In this letter, we demonstrate multibeam emission and spatial wavelength demultiplexing using plasmonic structures. We report simulations and experimental results for two different lasers. In the first, a single-wavelength QCL produces two small-divergence beams with approximately equal peak intensity. In the second, a QCL emits two wavelengths in different directions.

Previously, a suitably designed aperture-grating plasmonic structure on a QCL facet was shown to collimate the emerging beam.8,9 The subwavelength aperture defined on the laser active region couples a substantial part of the laser output into propagating surface plasmons (SPs). If the period of the plasmonic grating is approximately equal to the SP wavelength, the waves scattered from the grating grooves and the aperture interfere constructively in the far field, yielding a collimated beam normal to the laser facet.8 If instead the grating period differs from the SP wavelength, waves from neighboring grooves will have a constant phase difference (different from 2π) and constructive interference will occur in a direction away from the normal of the facet.11–14

We utilized this concept to split the emission of a single wavelength QCL into two collimated beams in different directions. Two successive plasmonic gratings with different periods and lengths were defined on the device facet. By tuning the grating period, the emission direction of the beam originating from each individual grating can be controlled; by tuning the grating length (i.e., the number of grooves per grating), we can independently control the intensity of the emitted beams. Note that since SPs are able to propagate for significant distances comparable to approximately 1000 wavelengths in the mid-infrared region,15 several gratings can therefore be patterned on the laser facet to produce multiple laser beams with controlled intensity and direction.

To design the structure, numerous rapid two-dimensional (2D) simulations using a finite element electromagnetic solver (COMSOL) were performed. After a promising design was found, it was verified by a full three-dimensional simulation using a finite-difference time-domain solver (Lumerical FDTD) running on a computational cluster.

Figure 1 shows experimental and simulation results for a single-wavelength laser emitting two beams. The grating closer to the aperture is designed to produce a beam propagating normal to the facet (i.e., grating period approximately equal to the SP wavelength). The grating farther away from the aperture has a smaller grating period [Fig. 1(a)]. It provides a reciprocal lattice vector larger than the wavevector of the SPs, and therefore light scattered from the grating grooves is deflected away from the normal toward the top electrical contact of the device. The deflection angle is designed to be approximately 20° from the surface normal, which is confirmed by simulations and experiments; see 2D far-field patterns in Fig. 1(b) and their line scans in Fig. 1(c). The 2D simulation, right half of Fig. 1(b), is in good agree-

a)Electronic mail: nya@fas.harvard.edu.
b)Present address: School of Electrical and Electronic Engineering & School of Physical and Mathematical Sciences, Nanyang Technological University, Nanyang Ave, 639798 Singapore.
c)Present address: Department of Electrical and Computer Engineering, The University of Texas at Austin, Austin, Texas 78758, USA.
d)Electronic mail: capasso@seas.harvard.edu.

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ment with the measured far-field, the left half of Fig. 1(b), including its curved features of the far-field patterns, which are due to edge effects originating from the finite lateral size of the aperture and gratings.

Since the intensity of SPs decreases as it propagates through the grating grooves due to both scattering from the grooves and losses within the metal, the second grating should contain more grooves than the first one to allow the two emitted beams to have the same peak intensity. Indeed, by including 11 and 25 grooves in the two gratings, respectively, we see from the line scans in Fig. 1(c) that the two lobes are approximately equal in peak intensity. The measured peak intensity of the narrower beam [upper panel of Fig. 1(c)] is slightly smaller than that predicted by simulations [lower panel of Fig. 1(c)]. This is most likely due to additional attenuation of SPs originating from scattering by inevitable surface roughness introduced in the fabrication process. This effect attenuates SPs before reaching the second grating. The two beams have different divergence, see Fig. 1(c), because the divergence angle is roughly inversely proportional to the number of the grooves in the grating.

The power output versus driving current characteristics (LI curves) of the device are presented in Fig. 2. Its peak output power is \(-60\%\) of that of the original device. The power output was measured using a calibrated thermopile detector that collects laser emission via a metallic tube right in front of the device facet.

For the lasers emitting spatially demultiplexed wavelengths, we used mid-infrared QCLs with two stacks of active regions: one based on a two-phonon design emitting at \(-10.5\ \mu\text{m}\) and the other based on a bound-to-continuum (BTC) design emitting at \(-9.3\ \mu\text{m}\). It is essential to devise a plasmonic grating structure that is efficient in scattering light at both wavelengths. Optimal grating geometry for one wavelength will not necessarily give good collimation for another wavelength because collimation is especially sensitive to the depth and width of the grating grooves. We chose a design that is the trade-off between the optimal structures for the two wavelengths: the groove depth (width) is 1.3(0.7) \(\mu\text{m}\), while the optimal groove depth (width) for \(\lambda =9.3\) and 10.5 \(\mu\text{m}\) is 1.1(0.7) \(\mu\text{m}\) and 1.6(0.7) \(\mu\text{m}\), respectively. We used a single grating with a period of 8.5 \(\mu\text{m}\) which deflects the \(\lambda =9.3\ \mu\text{m}\) component away from the facet normal toward the top contact by \(-3^\circ\) and the \(\lambda =10.5\ \mu\text{m}\) component by \(-12^\circ\).

Simulations and experimental results for a dual-wavelength device are presented in Fig. 3. The grating contains 30 grooves; see Fig. 3(a). A 9.5 \(\mu\text{m}\) short-pass filter was placed in front of the mid-infrared detector to allow mapping of the far-field pattern of the \(\lambda =9.3\ \mu\text{m}\) component; the result is shown in the left half of Fig. 3(b). The emission pattern of the \(\lambda =10.5\ \mu\text{m}\) component is shown in the left half of Fig. 3(c), which is obtained by subtracting the contribution of the \(\lambda =9.3\ \mu\text{m}\) component from the far-field pattern measured using the detector without the filter. The measured direction and divergence angle of the two beams are in agreement with simulations; see Fig. 3(d) for the vertical line scans of Figs. 3(b) and 3(c). Our original unpatterned device lased on the fundamental TM\(_{00}\) mode for both wavelengths with only one lasing spot as confirmed by far-field measurements. After patterning the plasmonic beam demultiplexer, the two components still lase in the TM\(_{00}\) mode corresponding to the single lobes in Figs. 3(b) and 3(c).

The LI curves of the dual-wavelength device before and after defining the plasmonic demultiplexer are plotted in Fig. 4. For the original laser, the \(\lambda =10.5\ \mu\text{m}\) component has a lower threshold current and an approximately five times larger slope efficiency than the \(\lambda =9.3\ \mu\text{m}\) component. With the beam demultiplexer, the laser threshold of the \(\lambda =10.5\ \mu\text{m}\) component increases from about 1.5 to 1.75 A as a result of increased losses due to the scattering of laser light at the metallic aperture on the facet. However, the laser threshold of the \(\lambda =9.3\ \mu\text{m}\) component does not change significantly (but is still higher than that of the other compo-
plexing component for dual-wavelength lasers can function as a demultiplexer for optical fiber communications.

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FIG. 4. LI characteristics of the dual-wavelength device measured before (dotted curves) and after patterning the demultiplexer (solid curves).


FIG. 3. (Color online) (a) Electron micrograph of a dual-wavelength QCL patterned with a demultiplexer. (b) Measured (left half) and simulated (right half) far-field emission patterns of the device at $\lambda=9.3$ $\mu$m. (d) Vertical line scans of (b) and (c) along the arrows. Upper and lower panels are, respectively, experimental and simulated results. Solid curves and dotted curves are for the $\lambda=9.3$ $\mu$m and $\lambda=10.5$ $\mu$m components, respectively.